Sheet 1 of I

FORM 1449 U.S. Department of Commerce Patent and Trademark Office INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use several sheets if necessary)						cket No.	Application No. 10/554,222		
						Applicant Toshihito MIYAMA et al.			
					I. A. Filir April 23,		Group 1729		
			U	J.S. PATENT DOCU	MENTS				
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE		
	A								
	В								
	C								
	D								
	E								
	F								
	G								
	Н								
	1								
	J								
			FOR	EIGN PATENT DO	CUMENTS				
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES	ENGLISH ABSTRACT YES	
	K	10-503788	04/07/98	JAPAN					
		1-366137	12/18/92	JAPAN					
	-14-	6-342665	12/13/94	JAPAN					
***************************************	N	8-249023	09/27/96	JAPAN					
	۵	10 92444	04/10/98	JAPAN					
	P	9.040911	02/10/07	JARAN					
	Q								
	R								
	S								
	Ţ								
	Ü								
		OTHER DOCU	MENTS (Incl	luding Author, Tit	le, Date, Pe	rtinent Page	es, Etc.)		
		Kawabara M., et e	L "Proton Cond	luction of Sulfeally la	ed Polybennin	idazole Films	(III)" Polymer Pre	prints,	
		Japan, Vol. 46, No	o. 9, 1997, pp. 1	867-1868.					
	2								
	3								
EXAMINER /Alix Echelmeyer/ DATE CONS						03/1	8/2011		
*EXAMINER: I conformance an	lnitia d not	l if citation considerer considered. Include	d, whether or not copy of this form	citation is in conformant with next communication	e with MPEP 60 on to applicant.	9; draw line thro	ough citation if not i	n	